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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/032,289	12/21/2001	Sergio Tommaso Spampinato	853063.497	4035

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EXAMINER

FARAHANI, DANA

ART UNIT PAPER NUMBER

2814

DATE MAILED: 11/20/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

10/032,289

Applicant(s)

SPAMPINATO, SERGIO
TOMMASO

Examiner

Dana Farahani

Art Unit

2814

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM
THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 26 September 2002.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-14 and 23-26 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-14 and 23-26 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on _____ is: a) ☐ approved b) ☐ disapproved by the Examiner.
- If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
- a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☐ Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____.
- 4) ☐ Interview Summary (PTO-413) Paper No(s) _____.
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other: _____.

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 1-4, 6-14 and 23-26 are rejected under 35 U.S.C. 102(b) as being anticipated by Aiello et al., hereinafter Aiello (U.S. Patent 6,127,723).

Regarding claims 1, 6-8 and 14, Aiello discloses in figure 2a an Integrated device being integrated in a chip of semiconductor material 218 of a first conductivity type, said chip having a first (lower) surface and a second (upper) surface opposite to each other, said device comprising a first transistor Td1 having a base region (242), an emitter region (251) and a collector region; a second transistor (comprising regions 218, 209, and 206) which is connected with the first transistor; a quenching element (pn junction of 242 and 218) of the first transistor, which discharges current there from when said second transistor is turned off, said quenching element being coupled with the base terminal of the first transistor and with the other not drivable terminal of the second transistor, said quenching element having at least one Zener diode made in polysilicon, said at least one polysilicon Zener diode being formed on the second surface of said chip and comprising a polysilicon layer having at least one zone of the first conductivity type and at least one zone of a second conductivity type in order to form at least one P-N junction.

Regarding claim 2, the chip comprises a first region 242 of the second conductivity type which extends from the second surface into the chip and a second region 251 of the first conductivity type which extends from the second surface into the first region, and the first region, the second region and a portion of the chip comprised between the first region and the first surface forming respectively the base region, the emitter region and the collector region of the first transistor.

Regarding claim 3, the first transistor and said second transistor are bipolar transistors and said chip comprises a third region 209 of the second conductivity type which extends from the second surface into the second region and a fourth region 218 of the first conductivity type which extends from the second surface into the third region, each of the first region, of the third region and of the fourth region forming respectively the collector region, the base region and the emitter region of the second transistor.

Regarding claim 4, a third bipolar transistor Td2 connected with the first transistor in a Darlington configuration and the collector terminal of the first transistor is connected with the collector terminal of the third transistor.

Regarding claims 9-12, the at least one polysilicon Zener diode comprises first and second polysilicon Zener diodes (one comprises regions 242 and 218; and the other is 209 and 206. Similarly, there are plurality of diodes corresponding to regions 239, 242 and 245) in back to back connection wherein the anode of the first Zener diode is connected with the anode of the second Zener diode and the cathode of the first Zener diode is connected with the base terminal of the first transistor and the cathode of

the second Zener diode is connected with said other not drivable terminal of the second transistor.

Regarding claim 13, 257 of figure 2a is an insulating layer (see column 3, line 50).

Regarding claims 23-26, Aiello discloses the limitations in the claims, as above discussed, further disclosing insulating layer 257 and polysilicon layer 218 on the insulating layer.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. Claim 5 is rejected under 35 U.S.C. 103(a) as being unpatentable over Aiello.

Aiello discloses in 2a the limitation in the claim, as above discussed, except for a MOS transistor.

Aiello discloses in figure 4a MOS transistor Me, third and fourth regions 410 and 420, respectively. It would have been obvious to one of ordinary skill in the art at the time the invention was made to make a MOS transistor in the embodiment of figure 2a in order to make the emitting-switching structure of figure 4b.

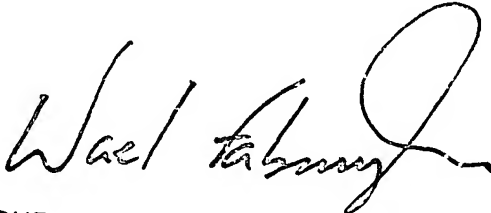
Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dana Farahani whose telephone number is (703)305-1914. The examiner can normally be reached on M-F 9:00AM - 6:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M Fahmy can be reached on (703)308-4918. The fax phone numbers for the organization where this application or proceeding is assigned are (703)872-9318 for regular communications and (703)872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0956.

Dana Farahani
November 13, 2002


SUPERVISORY PRIMARY EXAMINER
TECHNOLOGY CENTER 2800